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Japanese Kokai Patent Application No. Sho 61[1986]-25763

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WORKPIECE HOLDING MECHANISM FOR A PLANE POLISHING DEVICE

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[There are no amendments to this patent.]

Claim

1. A workpiece holding mechanism for a plane polishing device characterized in that it contains a holding part, which holds a workpiece that is on top of the polishing surface of the plane polishing device and is equipped with a convex spherical surface centering around one point on the surface of the said workpiece to be processed; a support part, which is provided for maintaining a constant orientation and is equipped with a concave spherical surface, which engages with the aforementioned convex spherical surface in a freely oscillating manner centering about one point on the aforementioned workpiece; and a flexible body, which is provided between the aforementioned holding part and the aforementioned supporting part and has high torsional rigidity but can bend freely.

## Detailed explanation of the invention

### Industrial application field

The present invention concerns a workpiece holding mechanism for a plane polishing device. In particular, it concerns a holding mechanism for a workpiece in a plane polishing device which polishes the surface of thin plates.

### Prior art

Generally, a workpiece holding mechanism for a plane polishing device is constructed to include a holding area, where the workpiece is held on top of a polishing surface of the plane polishing device, and the surface of the workpiece is polished by oscillating [vibrating while moving] the workpiece over the polishing surface.

Figure 2 is a longitudinal section of a workpiece holding mechanism for a plane polishing device of the prior art. In Figure 2, a disk (1) of the plane polishing device is rotated about a shaft (2). Also, a sleeve (4) is attached to a frame (3) of the plane polishing device in a freely rotatable manner, and a splined shaft (5) is attached to the central hole of this sleeve (4) in a freely movable manner in the direction of the shaft and in such a manner that it rotates together with the sleeve (4) about the shaft. A lever (7), which is attached to an air cylinder (6) provided for the frame (3), engages with the splined shaft (5) in a freely rotatable manner. Also, a gear (9), which is attached to a motor (8) provided for the frame (3), engages with a gear (10), which is provided at the sleeve (4).

A hemispherical body (11) engages with the curved area in the form of a spherical surface that is provided at the front end of the splined shaft (5) in a freely oscillating manner. A pressing plate (12) is fixed to the hemispherical body (11), and a frame (13) is provided at the pressing plate (12). A pin (14), which is provided at the frame (13), engages with a groove (15), which is provided at the front end of the splined shaft (5). A compression spring (16), which is provided between the splined shaft (5) and the frame (13), interacts to press the hemispherical body (11) onto the splined shaft (5) in order to prevent the hemispherical body (11) from falling when the splined shaft (5) ascends.

A through-hole (17), which is provided at the pressing plate (12), and a through-hole (18), which is provided between the hemispherical body (11) and the pressing plate (12), are connected to a vacuum pump (not shown) through a pipe (19), which passes through a hole provided at the splined shaft (31), in order to vacuum hold material (20), which is a magnetic disk forming the workpiece, onto the pressing plate (12). A ring (21) is also provided and fixed at the pressing plate (12) in order to determine the position of the material (20).

To polish the surface of the material (20) with this plane polishing device, the air cylinder (6) is actuated so that the pressing plate (12) ascends and so that the material (20) is vacuum held against the inner side of the ring (21) at the lower surface of the pressing plate (12). Next, the pressing plate (12) is lowered by the air cylinder (6) through rotation of the motor (8), and the material (20) is pressed against the polishing surface (22) of the disk (1). Also, a polishing solution (not shown) is spread over the polishing surface (22). Accordingly,

the bottom surface of the material (20) is polished by the action of its own rotations and vibrations by the rotation of the disk (1).

The polishing surface (22) of the disk (1) is processed to have a flat surface; however, a small amount of waviness remains in many actual cases. Accordingly, it is necessary for the material (20) and the pressing plate (12) to be able to tilt slightly along the waviness of the polishing surface (22) in order for the material (20) constantly to adhere close to the polishing surface (22) for a smooth finish. This tilting is obtained when the hemispherical body (11) vibrates with the spherical concave area of the splined shaft (5). Moreover, the material (20) tilts while centering around the center C because the center C of the spherical surface of the hemispherical body (11) is established to be positioned at the bottom surface of the material (20), and the position of the bottom surface of the material (20) does not change even though it is tilted, and polishing can occur.

The pipe (19) is elastic and can absorb some tilting in the hemispherical body (11). Also, the hemispherical body (11) vibrates around the splined shaft (5); therefore, it is designed so that the rotation by the motor (8) is transmitted to the pressing plate (12) and the material (20) when the pin (14) engages with the groove (15).

#### **Problems to be solved by the invention**

However, the ability of the pressing plate (12) and material (20) to follow the waviness of the polishing surface (22) was not satisfactory. One factor is the generation of a large amount of

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friction between the pin (14) and the groove (15). Figure 3 is a schematic diagram explaining the force that is applied to the pin (14), and it corresponds to the right side surface diagram of the major part in Figure 2. In Figure 3, force b, which is equal to the friction between the material (20) and the polishing surface (22), is applied to the groove (15) from the pin (14) when the splined shaft (5) rotates, as illustrated by arrow a. Furthermore, since a condition is created, in which the right side opens between the material (20) and the polishing surface (22), as illustrated in Figure 1, by the waviness of the polishing surface (22), and if force P is obtained by the piston (6), force P interacts upwards at the left edge of the material (20). To consider the equilibrium of the moment about center C, where the length between center C of the spherical surface of the hemispherical body (11) and the left edge of the material (20) is d and the height between center C and the pin (14) is h, a force of  $Pd/h$  is also applied to the pin (14). In practice, this force P becomes considerably large; therefore, a large force also acts on the pin (14), resulting in a large frictional force.

There was also the problem of the pin (14) being constantly pressed toward the left by the groove (15) in Figure 3, causing the pressing plate (12) to swing around the pin (14) according to the waviness of the polishing surface (22), the base ([illegible]) of the pin (14) to change its position to the left or the right relative to the splined shaft (5), and a fluctuation to occur in the rotation of the pressing plate (12).

The aim of the present invention is to offer a workpiece holding mechanism for a plane polishing device in which the aforementioned problems are solved, there is a satisfactory following of the waviness of the polishing surface by tilting of

the workpiece, and the fluctuation in the rotation of the workpiece is reduced for a smooth polishing of the workpiece.

#### Means to solve the problems

The present invention comprises a holding part (34), which holds the workpiece that is on top of the polishing surface of the plane polishing device and is equipped with a convex spherical surface centering around one point on the surface of the said workpiece to be processed; a support part (32), which is provided for maintaining a constant orientation and is equipped with a concave spherical surface, which engages with the aforementioned convex spherical face in a freely vibrating manner centering about one point on the aforementioned workpiece; and a flexible body (36), which is provided between the aforementioned holding part (34) and the aforementioned support part (32) and has high torsion rigidity but can bend freely.

#### Function

The elastic body (36), which has torsional rigidity but can bend freely, tilts the holding part (34) against the support part (32) while following the waviness of the polishing surface and not generating a large amount of friction. During this process, the holding part (34) does not separate from the support part (32) in the direction of rotation.

Application example ..

Next, an application example of the present invention will be explained with reference to a figure. Figure 3 [sic; 1] is a longitudinal section of an application example of the present invention. A disk (1), shaft (2), frame (3), sleeve (4), air cylinder (6), lever (7), motor (8), and gears (9) and (10) are the same as those illustrated in Figure 1 [sic; 2]. A splined shaft (31) is attached to the sleeve (4) so that it can freely oscillate in the direction of the shaft and rotate together with it around the shaft. A hemispherical body (33) engages with the concave part in the form of a spherical surface, which is provided at a flange (32) at the lower end of the splined shaft (31) in a freely oscillating manner. A pressing plate (34) is fixed to the hemispherical body (33). A through-hole (35) of the pressing plate (34) is connected to a pipe (19) in order to hold the material (20) against the pressing plate (34).

The upper end of bellows (36) is fixed to the flange (32) and its lower end to the pressing plate (34). The torsional rigidity of the bellows (36) with respect to the central shaft is high, but it can expand and bend in the direction of the central shaft; therefore, the pressing plate (34) does not separate from the flange (32) in the direction of rotation, but it can tilt freely. Accordingly, a large frictional force is not generated even when the pressing plate (34) is tilted, and the pressing plate (12) and the material (20) satisfactorily follow the waviness of the polishing surface.

The present invention can also be applied to plane polishing devices, in which the disk is fixed, and the pressing plate (34),

for example, rotates together with the frame (3) around the shaft (12).

A steel ball, for example, may also be included between the concave spherical surface of the supporting part and the convex spherical surface of the holding part so that the friction can be reduced.

Furthermore, the elastic body that is provided between the support part and the holding part does not necessarily have the form of a bellows. For example, dividing the bellows in the circumferential direction, in other words, several plate springs that are bent in the middle and arranged over the circumference may also be used.

#### Effect of the invention

As explained above, in the workpiece holding mechanism for a plane polishing device of the present invention, the holding part is tilted without the generation of a large amount of friction between the groove and the pin by using an elastic body which has torsional rigidity but which can expand and bend freely, instead of an engagement between the groove and the pin, and the workpiece can satisfactorily tilt with and follow the waviness of the polishing surface.

Also, oscillations around the pin are eliminated when the support part is tilted, a fluctuation in the rotating speed of the workpiece can be made very small, and the effect is smooth polishing of the workpiece.

Brief description of the figures

Figure 1 is a longitudinal section of an application example of the present invention. Figure 2 is a longitudinal section of an example of a workpiece holding mechanism for a plane polishing device of the prior art. Figure 3 is a model diagram which explains the force which interacts on the pin (14) as an example illustrated in Figure 2.

1...disk, 5, 31...splined shaft, 11, 33...hemispherical body, 12, 34...pressing plate, 14...pin, 15...groove, 20...material, and 36...bellows.

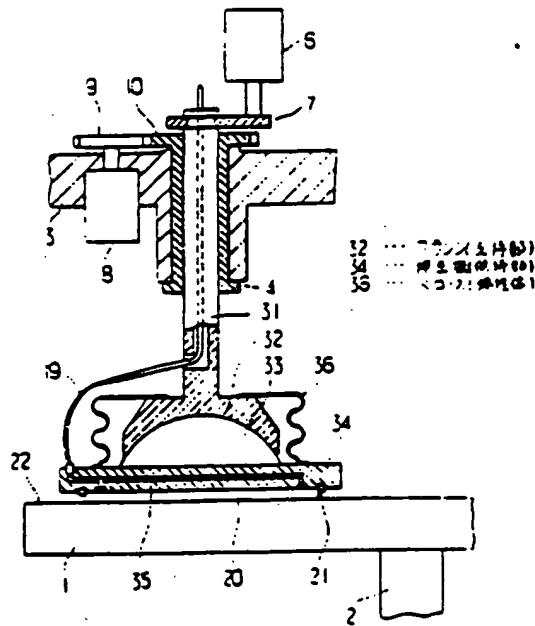


Figure 1

Key:

- 32 Flange (supporting part)
- 34 Pressing plate (holding part)
- 36 Bellows (elastic body)

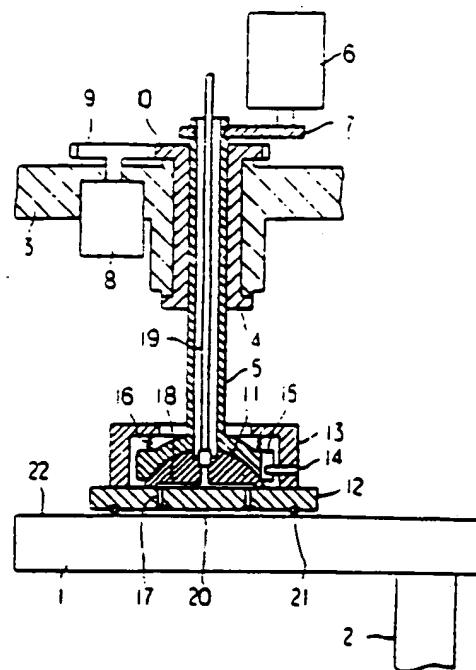


Figure 2

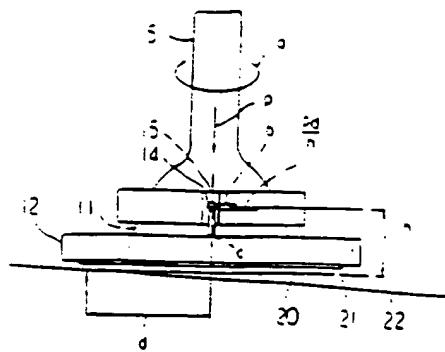


Figure 3

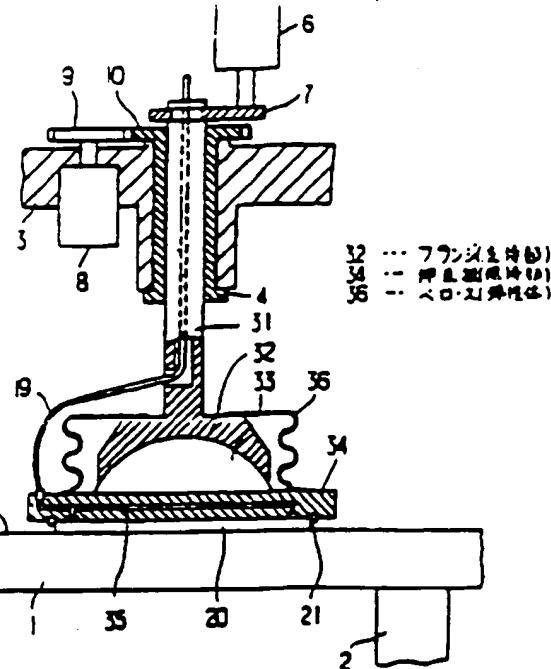
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INVENTOR : KAMATA TAKEMI; others: 01

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**TITLE : WORK HOLDING MECHANISM FOR SURFACE POLISHING MACHINE**



**ABSTRACT :** PURPOSE: To polish a work smoothly by providing a resilient bellows between the work holding section having convex face and the supporting member having concave face engagable slidably with the convex face.  
**CONSTITUTION:** Semi-spherical body 33 secured to a pressboard 34 is engaged slidably with spherical recess made in the lower end flange 32 of spline shaft 31 to adsorb a material 20 through a hole 35 communicated with a tube 19 to the pressboard 34. A bellows 36 having high rigidity in the rotary direction while flexible against the vertical shrinkage and bending is secured between said flange 32 and the pressboard 34. Consequently, the work 20 or the pressboard 34 will follow the waving of the polishing face 22 well to reduce the fluctuation of the rotary speed of the work 20 thus to polish the work 20 smoothly.

①日本国特許庁 (JP)

②特許出願公開

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審査請求 未請求 免明の段 1 (全4頁)

⑥発明の名称 平面研磨装置の被加工物保持機構

⑦特許 昭59-145408

⑧出願 昭59(1984)7月13日

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明細書

1. 発明の名称

平面研磨装置の被加工物保持機構

2. 特許請求の範囲

①平面研磨装置の研磨面上の被加工物を保持し、この被加工物の研磨面上の一端を中心とする凸部を有する保持部と、保持部を一定の角度で置かれた被加工物上の一端を中心とした凸部に該保持部が直接接する凹部を有する支持部と、支持部と前記支持部の間に設けられた取付部では前記が大きく曲げに対しても柔軟な保持部とを有することを特徴とする平面研磨装置の被加工物保持機構。

3. 発明の詳細な説明

(1) 研磨面上の構成部分)

本発明は、平面研磨装置の被加工物保持機構、特に被加工物の持続を困難するための平面研磨装置の被加工物保持機構に関するものである。

(2) 前記の構成)

一般的な平面研磨装置の被加工物保持機構は、平

面研磨装置の研磨面上の被加工物を保持する保持部を含んで構成され、研磨面上において被加工物を複数点で多角形の形状を形成している。

本発明は、従来の平面研磨装置の被加工物保持機構の構成範囲である。即ち既にいて平面研磨装置の円盤上は輪郭を中心として周辺を形成される。一方平面研磨装置のフレームにはスクリーフが固定自在に取り付けられ、このスクリーフの中心でビスアライメントが四方角は輪郭自在に取り付けられる。フレームに設けられたエンドランナーやランナーハウジング等が取り付けられた以外ではスクリーフは固定自在に取付けられている。またスクリーフは取付けたままに取り付けた状態を維持する事により取付け位置を10度まで可変している。

スクリーフの丸周に設けた輪郭状の、基部を球体部が複数個存在しておる。球体部は球座部が取付けられておる。球座部は取付け部をビス接合部、スクリーフの表面との共同部で支持を負担している。

エアライン端子と車の間に設けられた空気ばね16及び被体11をスマートライン端子に押しつけるよう作用し、スマートライン端子が上昇したとき被体11が落下するのを防止している。

押圧板12に受けられた通過孔17及び半球体11と押圧板12の間に設けられた通過孔18は、スマートライン端子11に受けた穴を通る貫通孔19を介して真空ポンプ(显示部等)に通路され、被加工物である被体11の裏面20を押圧板12で真空吸着するためのものである。また貫通孔20の位置を決めるために押圧板12にリニア孔が設置されている。

この平面研磨装置で貫通孔20の位置を研磨するには、エアシリンダ10を作動させて押圧板12を上昇させ、貫通孔20を押圧板12の下部のリニア孔21の内側に真空吸着させる。次にモータ14により回転させながら押圧板12をエアシリンダ10により下降させ貫通孔20を半球体11の研磨部端面に押し付ける。また図には示していないが研磨面22には、研磨液が附着されている。皮つて貫通孔の下部は、自らの回転及び円錐1の回転による運動で研磨される。

したがつてある。第3図は、ビン16に作用する力を説明するための截面図で、第3図の主眼鏡の右側面に表示する。第3図の矢印と表示するようにスマートライン端子が回転していれば貫通孔と研磨面22との摩擦力に負う力Fがビン16によりビン16に加えられる。さらに研磨面22のうねりにより貫通孔20と研磨面22との間に常に図に示すように右側が高く状態になつたとし、ビストン18により力Fが負えられるとすると貫通孔の左側に上向きに力F'が働く。半球体11の裏面の中心と貫通孔の左端までの半径をr、中心Cからビン16までの高さをHとしたし、中心Cをカタツムリのマーカーの角を負えるとビン16には  $\frac{Fr}{r}$  の力も作用する。実際にはこの力F'がかなり大きくなるためビン16にも大きな力が作用したときに摩擦力が生じてい。

また、第3図においてビン16は貫通孔20により常に左向きに押されることとなり研磨面22のうねりによって押圧板12はビン16を中心として回り回れりもこととなり、スマートライン端子に押して被加工物ビン16の後ろへは逆方に定位し、押圧板12の裏面

面室1の表面面22が、半球体11とともにこれでこじれてからが実際には強かであらかじめが残されていいる場合が多い。皮つて貫通孔20を研磨面22に當てて押すとてきらかに研磨するには、貫通孔20を少しおよび12を研磨面22のうねりに沿つてまん延ぐことができるようすらと見がれる。この場合は、半球体11のエアシリンダ端子の裏面の凹部との間に隙間で残られ、しかもも半球体11の裏面の中心とが貫通孔20の下面に位置するようく配置されているので貫通孔20は中央Cを中心として傾き、傾いても貫通孔20から出る位置は変化せずに研磨することができる。

なお貫通孔20に慣性を有し半球体11の回転は緩慢である。また半球体11がスマートライン端子に押し運動するため、ビン16と貫通孔20の底面により押圧板12及び貫通孔22までモーター14による回転が終わるようにしている。

#### (発明が解決しようとする問題)

しかし、押圧板12及び貫通孔20の研磨面22のうねりに対する適応性はあまりよくなかつた。この原因の一つはビン16と貫通孔20の間に大きさを調節力が生

じるためである。第3図は、ビン16に作用する力を説明するための截面図で、第3図の主眼鏡の右側面に表示する。

本発明の目的は、上記欠点を取除し、被加工物の端子の研磨面のうねりに対する適応性がよく、また被加工物の回転運動を少くして円滑に被加工物を研磨することができる平面研磨装置の被加工物保護装置を提供することにある。

#### (開発本を構成するための手段)

本発明は、平面研磨装置の供給面上の被加工物を保持しこの被加工物の被加工面上の一端を中心とする凸凹部を有する保持部34と、位置を一定に保つて動作するモーター32と被加工面上の一端を中心とした凸凹部を有する保持部を有する支持部33と、所述支持部33と所述支持部34との間に設けられた開口部にては差動を半球体11と有する

#### (作用)

ねじり式にしては慣性をもじきげに押しては最初を貫通孔20は支持部33を支持部32に押し伊藤壁のうねりに適応させて大きな摩擦力を生じることなく、運動させる。その結果支持部33は支持部34に

特開昭61-25758(3)

内し西輪方向にはされない。

(実用例)

次に本発明の実用例について図面を参照して説明する。第3図は本発明の一実用例の断面構造である。円筒1、軸2、フレーム3、スライド4、ニアリング5、レバー7、カーブ8、油墨9.10は第1図に示すものと同じである。スライド4は、輪方向へは運動自在で輪幅わたりに一體とをつて回転するようハリーフ11に取り付けられている。スライド4の下端のフランジ32に嵌けた部品状の保持部33が運動自在に係合している。保持部33は押圧板34が固定されている。押圧板34の通過孔35は貫通と高精度な油墨頭を押圧板34に使用するためのものである。

ベローズ36が上端をフランジ32に接着し下端を押圧板34に固定して抜けられている。ベローズ36は中心輪幅わたりのねじりに対しても剛性が大きいのに対し、中心輪方向の伸縮及び曲げに対しては柔軟であるため、押圧板34はフランジ32に対し輪幅方向にはされないが、しかも自由に傾くことが

できる。以って押圧板34が傾くときも入力を押す力に生じず押圧板34及び油墨20の摩擦力をうねりに応する適度性はない。

上記が実用例、円盤が固定してあるつてシーム3とともに押圧板34等が輪2を中心として回転するような平滑研磨装置にも適用できる。

また保持部の凹字面と保持部の凸字面の間に油墨等を介在させて、摩擦力を減少させることもできる。

さらに支持部と保持部との間に設ける弹性体は必ずしもベローズの形状をしている必要はない。例えばベローズを輪幅方向に分割したものが、言い曾夫れ柱や間を電離させた電波の吸収力を円周上に並べたものでもよい。

(発明の効果)

本発明の平滑研磨装置の被加工物保持機構は、以上説明したように歯とピンの組合の代わりにねじりには剛性を有し伸縮及び曲げに対して柔軟性のある弹性体を用することにより、歯とピンとの間の大きさを摩擦力を発生させることなく保持す

が可能、研磨面のうねりに対する被加工物の傾きの適度性をよくすることができる。

また保持部が傾くときにピンを中心として運動することがなくなり被加工物の研磨速度の変動を非常に小さくすることができます、円筒に被加工物を保持できる効果がある。

(実用の意味を説明)

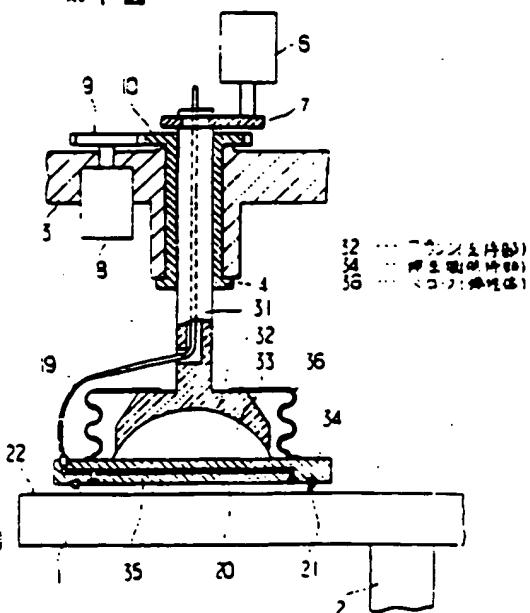
第1図は本発明の一実用例の断面構造、第2図は平滑研磨装置の被加工物保持機構の歯と一例の研磨面、第3図は第2図に示す一例のピン16に作用する力を説明するための模式図である。

1. 円筒、3.31. スライド、11.33. 中輪体、12.36. 押圧板、14. ピン、15. 9.20. 油墨、36. ベローズ、

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第1図



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図2

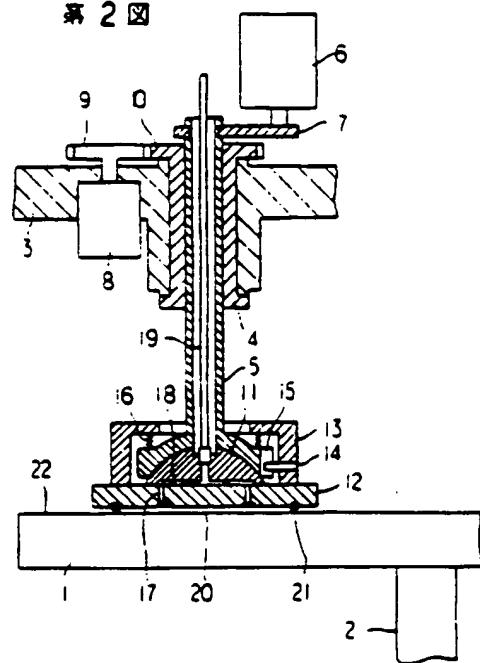


図3

